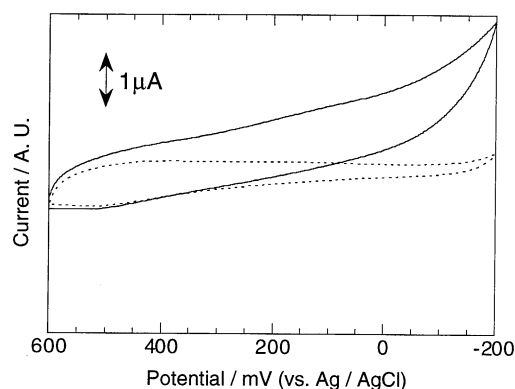




mol dm<sup>-3</sup>) in CH<sub>2</sub>Cl<sub>2</sub> for 4 days.<sup>6,8</sup> After soaking the electrode was washed well with CH<sub>2</sub>Cl<sub>2</sub> and dried with a stream of N<sub>2</sub>. Formation of self-assembled monolayer was confirmed by monitoring reductive wave due to breaking of the S-Au linkage using linear sweep voltammetry in water containing 0.5 mol dm<sup>-3</sup> KOH<sup>8</sup> and by oxidative wave of the porphyrin chromophore using cyclic voltammetry in CH<sub>2</sub>Cl<sub>2</sub> containing 0.1 mol dm<sup>-3</sup> Bu<sub>4</sub>NPF<sub>6</sub>.<sup>13</sup> From this oxidative wave, the surface coverage of porphyrin moiety was evaluated to be ~7 x 10<sup>-12</sup> mol cm<sup>-2</sup> for 1 - Au.



**Figure 1.** *i* / *V* curves for Au / 1 / methylviologen / Pt cell in water under illumination (full line) and dark (dashed line). Ag / AgCl was the reference electrode. Sweep rate, 10mVs<sup>-1</sup>, [Na<sub>2</sub>SO<sub>4</sub>] = 0.1 mol dm<sup>-3</sup>; [methylviologen] = 5 x 10<sup>-3</sup> mol dm<sup>-3</sup>.

Electrochemical measurements were carried out using Pyrex cell consisting of modified Au electrode, Ag / AgCl as a reference electrode, and platinum electrode as a counter electrode. The electrode 1 - Au was irradiated with 150W Xenon lamp. The photocurrent-voltage curves were shown in Figure 1. At the negative potentials, the cathodic photocurrents were clearly seen for 1 - Au in the presence of methylviologen.<sup>12</sup> In contrast, no apparent photocurrent was detected for that of 2 - Au. The mechanism for generating photocurrent is not clear at this moment, but it may be produced by electron relay via the excited singlet or triplet states of the porphyrin and the C<sub>60</sub>.

We thank Mr. Yoshiyuki Okuda, Technical Expert Workshop of ISIR, Osaka University, for his contribution of formation and measurements of flat gold electrode. This work was supported by the Grant-in Aids (No. 07454166 to Y. S.) from the Ministry of Education, Science, Sports and Culture, Japan. H. I. thanks Foundation Advanced Technology Institute for financial support.

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- 1:** <sup>1</sup>H-NMR (270 MHz, CDCl<sub>3</sub>) δ -2.70 (br.s, 2H), 1.53 (s, 36H), 2.71 (s, 3H), 2.86 (s, 3H), 3.36 (d, 1H, J=8.6 Hz), 3.92 (s, 1H), 4.45 (d, 1H, J=8.6 Hz), 7.60 (d, 2H, J=8.6 Hz), 7.78 (br.s, 2H), 7.80-8.20 (m, 10H), 8.70-9.00 ppm (m, 8H). <sup>13</sup>C-NMR (67.5 MHz, CDCl<sub>3</sub>) δ 31.2, 31.6, 32.0, 32.4, 35.1, 67.7, 75.8, 76.2, 78.0, 78.6, 119.3, 119.5, 120.5, 121.5, 121.8, 122.2, 123.3, 125.0, 125.6, 129.4, 130.4, 131.6, 133.5, 134.0, 135.0, 135.9, 136.2, 138.1, 138.2, 138.6, 138.7, 139.1, 139.5, 140.5, 140.6, 140.7, 141.0, 141.2, 141.4, 141.5, 141.7, 141.8, 142.4, 142.6, 142.9, 143.1, 143.3, 143.5, 143.7, 143.8, 143.9, 144.1, 144.2, 144.3, 144.8, 145.0, 145.1, 145.2, 145.3, 146.4, 148.8, 151.0, 152.1, 154.8 ppm. MS (FAB) 1662 (M+1)<sup>+</sup>. UV-Vis (THF) λ max 420, 515, 552, 591, 649 nm. **2:** <sup>1</sup>H-NMR (270 MHz, CDCl<sub>3</sub>) δ -2.69 (br.s, 2H), 1.53 (s, 54H), 2.72 (s, 3H), 7.61 (d, 2H, J=8.3 Hz), 7.79 (t, 2H, J=2.0 Hz), 7.80 (t, 1H, J=1.6 Hz), 8.09 (d, 2H, J=1.6 Hz), 8.10 (d, 4H, J=2.0 Hz), 8.15 (d, 2H, J=8.3 Hz), 8.91-8.86 ppm (m, 8H). MS (FAB) 998 (M+1)<sup>+</sup>. UV-Vis (THF) λ max 420, 515, 552, 593, 650 nm. **3:** <sup>1</sup>H-NMR (270 MHz, C<sub>6</sub>D<sub>6</sub>: CS<sub>2</sub>=1 : 3) δ 1.25 (s, 18H), 2.76 (s, 3H), 4.13 (d, 1H, J=4.6 Hz), 4.79 (d, 1H, J=4.6 Hz), 4.82 (s, 1H), 7.24 (m, 1H), 7.58 ppm (m, 2H). <sup>13</sup>C-NMR (67.5 MHz, C<sub>6</sub>D<sub>6</sub>) δ 29.9, 31.3, 39.6, 69.8, 70.7, 83.9, 121.5, 128.43, 136.0, 141.6, 141.9, 142.0, 143.0, 144.2, 146.2 ppm. MS (FAB) 1040 (M+1)<sup>+</sup>.
- Electrodes with flat gold surface were purchased from SHIBAO. The electrode was prepared by vacuum deposition of gold on Si (100) wafer (SUMITOMO SITX CORP); S. E. Creager, L. A. Hockett, and G. K. Rowe, *Langmuir*, **8**, 854 (1992). It was confirmed by atomic force microscopy that the surface has (111) plane.